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PATENTS
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Douglas A. Buchanan, et al.

Examiner: Jeff B. Vockrodt

Serial No: 09/553,997

Art Unit: 2822

Filed: April 20, 2000

Docket: YOR920000036US1 (13322)

For: PRECURSOR SOURCE MIXTURES,
METHODS OF FILM DEPOSITION,
AND FABRICATION OF STRUCTURES

Dated: March 27, 2002

Assistant Commissioner for Patents
United States Patent and Trademark Office
Washington, D.C. 20231

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RESPONSE UNDER 37 C.F.R. §§1.111 AND 1.143

MAR 27 2002

TECHNOLOGY CENTER 2800

Sir:

In response to the Office Action dated February 27, 2002, applicants provisionally elect precursor compounds wherein R¹ is a hydride group.

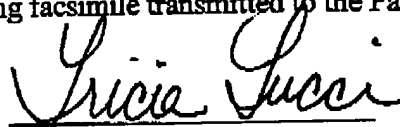
REMARKS

Favorable consideration and allowance of the claims of the present application are respectfully requested.

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that this paper is being facsimile transmitted to the Patent and Trademark Office on the date shown below.

Dated: March 27, 2002


Tricia Tucci